



Rec'd PCT/PTO 30 AUG 2001
PATENT APPLICATION #6

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Fumiaki MARUYAMA et al.

ATTN: Application Branch

Application No.: 09/856,139

Attorney Dkt. No.: 107242-00017

Filed: May 29, 2001

For: WAFER AND EPITAXIAL WAFER, AND MANUFACTURING PROCESSES
THEREFOR

REQUEST FOR CORRECTED FILING RECEIPT

Commissioner for Patents
Washington, D.C. 20231

August 30, 2001

Sir:

A corrected filing receipt is hereby requested in view of the errors which appear in the original filing receipt as follows:

Please change the title to read --**WAFER AND EPITAXIAL WAFER, AND MANUFACTURING PROCESSES THEREFOR**-- instead of "WAFER, EPITAXIAL FILTER, AND METHOD OF MANUFACTURE THEREOF"

For the convenience of the Patent and Trademark Office, attached is a photocopy of the original filing receipt on which the errors have been noted in red and a copy of the declaration with the corrected information highlighted.

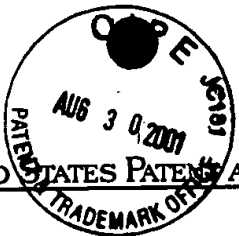
Please charge any deficiency or credit any overpayment with respect to this paper to Deposit Account No. 01-2300.

Respectfully submitted,

David T. Nikaido
Registration No. 22,663

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APPLICATION NUMBER	FILING DATE	GRP ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLAIMS	IND CLAIMS
09/856,139	05/29/2001	2811	2058	107242-00017	13	51	11

CONFIRMATION NO. 3293

004372

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FILING RECEIPT



OC000000006318553

Date Mailed: 07/19/2001

Receipt is acknowledged of this nonprovisional Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Customer Service Center. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

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Domestic Priority data as claimed by applicant

THIS APPLICATION IS A 371 OF PCT/JP00/06406 09/20/2000

Foreign Applications

JAPAN 11-277255 09/29/1999

Projected Publication Date: N/A

Non-Publication Request: No

Early Publication Request: No

REVIEWED IN

DOCKETING BY *limited*DATE 7-25-01/WE

Title

Wafer, epitaxial filter, and method of manufacture thereof

WATER AND EPITAXIAL WATER, AND MANUFACTURE PROCESSES THEREFOR

Preliminary Class

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